L Number	Hits	Search Text	DB	Time stamp
1	1072	(hemi\$spher\$4 adj (silicon or Si) or HSG)	USPAT	2004/03/19
2	578	and capacitor ((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$1resist or	USPAT	12:54 2004/03/19 12:55
3	555	resist or photo\$1sensitive) (((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$1resist or	USPAT	2004/03/19 10:18
4	85	resist or photo\$1sensitive)) and @ay<=2001 ((((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$1resist or resist or photo\$1sensitive)) and	USPAT	2004/03/19 14:25
5	920	<pre>@ay&lt;=2001) and (under\$1cut\$3 or expand or expanding) (hemi\$spher\$4 adj (silicon or Si) or HSG)</pre>	US-PGPUB;	2004/03/19
1		and capacitor	EPO; JPO; DERWENT; IBM_TDB	11:26
6	252	((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$lresist or resist or photo\$lsensitive)	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/19 11:26
7	157	(((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$lresist or resist or photo\$lsensitive)) and @ay<=2001	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/19 11:27
8	24063	capacitor and (photo\$1resist or resist or photo\$1sensitive)	USPAT	2004/03/19 12:55
9	2389	(capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4	USPAT	2004/03/19 12:56
10	1479	((capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4) and (side\$1wall or (side adj wall))	USPAT	2004/03/19 12:56
11	1316	(((capacitor and (photo\$lresist or resist or photo\$lsensitive)) and isotropic\$4) and (side\$lwall or (side adj wall))) and (plasma or anisotropic\$4)	USPAT	2004/03/19 12:57
12	1206	<pre>((((capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4) and (side\$1wall or (side adj wall))) and (plasma or anisotropic\$4))</pre>	USPAT	2004/03/19 12:57
13	922	and (hole or opening or via) (((((capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4) and (side\$1wall or (side adj	USPAT	2004/03/19 12:57
¥		<pre>wall))) and (plasma or anisotropic\$4)) and (hole or opening or via)) and (poly\$1silicon or (poly\$1cryalline adj silicon))</pre>	×	
14	892	<pre>((((((capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4) and (side\$1wall or (side adj</pre>	USPAT	2004/03/19 12:58
		<pre>wall))) and (plasma or anisotropic\$4)) and (hole or opening or via)) and (poly\$1silicon or (poly\$1cryalline adj silicon))) and @ay&lt;=2001</pre>		
15	251	<pre>((((((((capacitor and (photo\$lresist or resist or photo\$lsensitive)) and isotropic\$4) and (side\$lwall or (side adj wall))) and (plasma or anisotropic\$4)) and (hole or opening or via)) and</pre>	USPAT	2004/03/19
		(poly\$1silicon or (poly\$1cryalline adj silicon))) and @ay<=2001) and (etch\$3 adj stop)		

16	242	<pre>(((((((((capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4) and (side\$1wall or (side adj wall))) and (plasma or anisotropic\$4))</pre>	USPAT	2004/03/19 12:59
17	214	and (hole or opening or via)) and (poly\$1silicon or (poly\$1cryalline adj silicon))) and @ay<=2001) and (etch\$3 adj stop)) not ((((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$1resist or resist or photo\$1sensitive)) and @ay<=2001) and (under\$1cut\$3 or expand or expanding)) (((((((capacitor and (photo\$1resist or resist or photo\$1sensitive)) and isotropic\$4) and (side\$1wall or (side adj wall))) and (plasma or anisotropic\$4)) and (hole or opening or via)) and	USPAT	2004/03/19 13:00
		(poly\$1silicon or (poly\$1cryalline adj silicon))) and @ay<=2001) and (etch\$3 adj stop)) not (((((hemi\$spher\$4 adj (silicon or Si) or HSG) and capacitor) and (photo\$1resist or resist or photo\$1sensitive)) and @ay<=2001) and (under\$1cut\$3 or expand or expanding))) and ((silicon adj nitride) or SiN or "Si.sub.3 N.sub.4" or oxy\$1nitride or		
18	9	SiON) Kwean-Sung-Un.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/19 14:27
19	18	Hwang-Jae-Seung.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2004/03/19 14:27
_	1984	<pre>capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))</pre>	USPAT	2004/03/18 09:35
_	1984	(capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (etch or etching)	USPAT	2004/03/18 08:23
_	1334	(capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))	USPAT	2004/03/18
_	124	<pre>((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or   (etch\$3 adj stop))) and (sidewall or   (side adj wall))) and (HSG or</pre>	USPAT	2004/03/18
_	24	(hemi\$1spherical adj silicon)) ("5252517"   "5364813"   "5434812"   "5468684"   "5497016"   "5753547"   "5885865"   "5895250"   "5981369"   "5985762"   "6015734"   "6077742"   "6080622"   "6168985"   "6168987"   "6194309"   "6251790"   "6255160"   "6268244"   "6300192"   "6417045"	USPAT	2004/03/18 08:31
-	22	"6436758"   "6500763"   "6511878"   "2001/0018248"   "2002/0000596"   "2002/0019107"   "2002/0028553").PN. ("4636833"   "5142438"   "5352623"   "5362632"   "5385863"   "5407534"   "5447881"   "5452178"   "5459345"   "5486488"   "5492850"   "5554557"   "5612558"   "5623243"   "5663085"   "5963804"   "6214688"   "6218260"   "6258691"   "6294437"   "6307730"   "6319771"   "2002/0039826").PN.	USPAT	2004/03/18 09:00

_	292	((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or	USPAT	2004/03/18 09:33
		<pre>(side adj wall))) and (transverse\$2 or under\$1cut\$3)</pre>		
_	273	<pre>(((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or</pre>	USPAT	2004/03/18
		<pre>(etch\$3 adj stop))) and (sidewall or (side adj wall))) and (transverse\$2 or</pre>		
		under\$1cut\$3)) not (((capacitor and		
		<pre>(photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or</pre>		
		(etch\$3 adj stop))) and (sidewall or (side adj wall))) and (HSG or		
_	264	<pre>(hemi\$1spherical adj silicon))) ((((capacitor and (photo\$1resist or</pre>	USPAT	2004/03/18
	201	resist or photo\$1sensitive) and		09:34
		<pre>(etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and</pre>		
	:	<pre>(transverse\$2 or under\$1cut\$3)) not (((capacitor and (photo\$1resist or resist</pre>		
		or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or		
,		(side adj wall))) and (HSG or (hemi\$1spherical adj silicon)))) and		
	222	@ay<=2001 (((((capacitor and (photo\$1resist or	USPAT	2004/03/18
	222	resist or photo\$1sensitive) and	USPAI	09:38
		<pre>(etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and</pre>		
		<pre>(transverse\$2 or under\$1cut\$3)) not (((capacitor and (photo\$1resist or resist</pre>		
		or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or		
		<pre>(side adj wall))) and (HSG or (hemi\$1spherical adj silicon)))) and</pre>		
		@ay<=2001) and ((silicon adj nitride) or		
		SiN or "si.sub.3 N.sub.4" or oxynitride or siON)		
_	202	<pre>((((((capacitor and (photo\$1resist or resist or photo\$1sensitive) and</pre>	USPAT	2004/03/18   09:40
		<pre>(etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and</pre>		
		(transverse\$2 or under\$1cut\$3)) not (((capacitor and (photo\$1resist or resist		
		or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or		
		(side adj wall))) and (HSG or	,	
		(hemi\$1spherical adj silicon)))) and @ay<=2001) and ((silicon adj nitride) or		
		SiN or "si.sub.3 N.sub.4" or oxynitride or siON)) not (ink or inkjet)		
_	168	<pre>(((((((capacitor and (photo\$1resist or resist or photo\$1sensitive) and</pre>	USPAT	2004/03/18
		<pre>(etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and</pre>		
		(transverse\$2 or under\$1cut\$3)) not		
		<pre>(((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or</pre>		
		(etch\$3 adj stop))) and (sidewall or (side adj wall))) and (HSG or		
		(hemi\$1spherical adj silicon)))) and @ay<=2001) and ((silicon adj nitride) or		
		SiN or "si.sub.3 N.sub.4" or oxynitride or siON)) not (ink or inkjet)) and		
		(poly\$1silicon or (polycrystalline adj silicon))		
-	143	(capacitor and (photo\$1resist or resist	USPAT	2004/03/18 09:52
		or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (HSG or		09.32
	l	(hemi\$1spherical adj silicon))		

_	19	((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (HSG or (hemi\$1spherical adj silicon))) not (((capacitor and (photo\$1resist or resist	USPAT	2004/03/18 09:55
		or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and (HSG or (hemi\$1spherical adj silicon)))		
_	7	("5937314"   "5963805"   "6037219"   "6046083"   "6090679"   "6121084"   "6174769").PN.	USPAT	2004/03/18 09:53
-	128	crown adj capacitor.	USPAT	2004/03/18
_	115	<pre>(crown adj capacitor) not ((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (HSG or (hemi\$1spherical adj silicon)))</pre>	USPAT	2004/03/18 10:02
_	11	("5391511"   "5436188"   "5545585"   "5597756"   "5604147"   "5821141"   "6043119"   "6046093"   "6080620"   "6107139"   "6335552").PN.	USPAT	2004/03/18 09:56
_	8	("5281549"   "5354705"   "5405796"   "5453403"   "5595929"   "5597756"   "5629237"   "5686337").PN.	USPAT	2004/03/18 09:57
_	920	(cylindric\$3 or cylinder) adj capacitor	USPAT	2004/03/18 10:04
_	322	((cylindric\$3 or cylinder) adj capacitor) and (photo\$1resist or resist or photo\$1sensitive)	USPAT	2004/03/18
-	293	(((cylindric\$3 or cylinder) adj capacitor) and (photo\$1resist or resist or photo\$1sensitive)) not ((((capacitor	USPAT	2004/03/18 10:05
		and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and (HSG or (hemi\$1spherical adj silicon))) or ((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (HSG or (hemi\$1spherical adj silicon))) or (crown adj capacitor))		
	84	<pre>((((cylindric\$3 or cylinder) adj capacitor) and (photo\$1resist or resist or photo\$1sensitive)) not ((((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (sidewall or (side adj wall))) and (HSG or (hemi\$1spherical adj silicon))) or ((capacitor and (photo\$1resist or resist or photo\$1sensitive) and (etch\$1stop or (etch\$3 adj stop))) and (HSG or (hemi\$1spherical adj silicon))) or (crown adj capacitor))) and (etch\$1stop or</pre>	USPAT	2004/03/18 10:06
		(etch\$3 adj stop\$4))		